Docket No.: 006301 USA/Consilium/Consilium/DK

PATENT/OFFICIA

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

f re Application of

Badri N. KRISHNAMURTHY et al.

Serial No. 09/928,474

Group Art Unit: 2812

Filed: August 14, 2001

Examiner: Andre' C. Stevenson

For:

EXPERIMENT MANAGEMENT SYSTEM, METHOD AND MEDIUM

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

Honorable Commissioner for Patents Alexandria, VA 22313-1450

Sir:

In accordance with the provisions of 37 C.F.R. 1.56, 1.97 and 1.98, the attention of the Patent and Trademark Office is hereby directed to the documents listed on the attached form PTO-1449. It is respectfully requested that the documents be expressly considered during the prosecution of this application, and that the documents be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

This submission does not constitute a representation that a search has been made or that no better art exists and does not constitute an admission or representation that any of the listed documents is material or constitutes prior art. If it should be determined that any of the listed documents does not constitute prior art under the United States law, Applicants reserve the right to present to the Office the relevant facts and law regarding the appropriate status of such document.

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Serial No. 09/928,474

Please charge the fee of \$180.00 under 37 CFR 1.17(p) to Deposit Account No. 08-0219. The Commissioner is hereby authorized to charge any additional fees that may be required for this submission, or credit any overpayment to deposit account no. 08-0219.

Respectfully submitted,

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OFE COLUMN STRADERS

EXAMINER

INFORMATION DISCLOSURE CITATION IN AN APPLICATION (PTO-1449)

ATTY. DOCKET NO. SERIA 006301 09/92 USA/Consilium/Consilium/ DK

SERIAL NO. 09/928,474

APPLICANT

Badri N. KRISHNAMURTHY et al.

FILING DATE August 14, 2001 GROUP 2812

U.S. PATENT DOCUMENTS

EXAMINER'S INITIALS	PATENT NO. DATE		NAME	CLASS	SUBCLASS	FILING	G DATE			
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	WO 01/11679	02/15/01	WIPO			X				
	WO 01/080306	10/25/01	WIPO			X	1			
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	2000. "Microsense	2000. "Microsense II Capacitance Gaging System." www.adetech.com.								

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to Applicant.

DATE CONSIDERED

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